

Surface structure and surface energy of InAs

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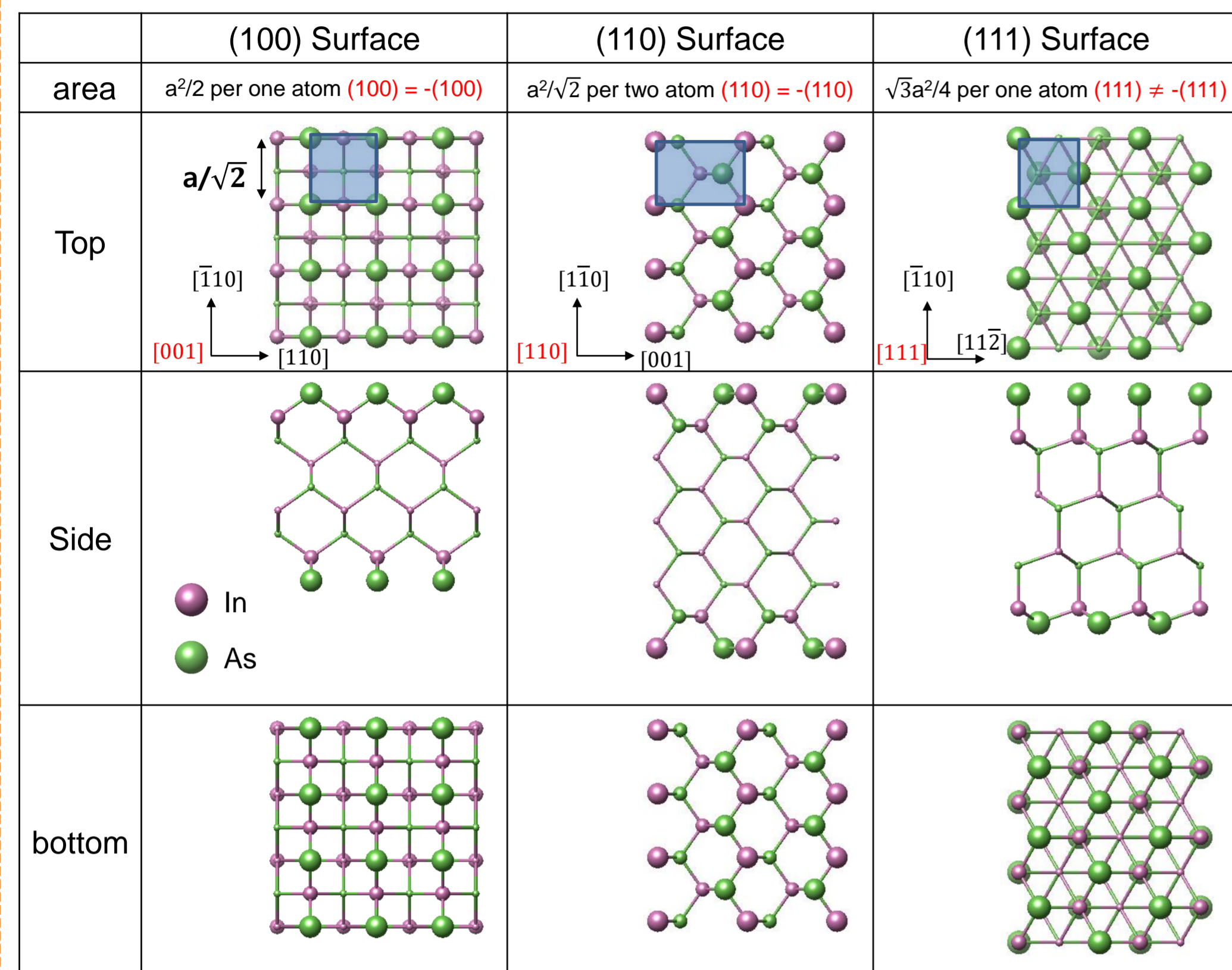


Computational Materials Design



INTRODUCTION

A. Zinc-blende unit surface



B. Motivation

- InGaAs : n-type channel material with high electron mobility (8000~30000 cm²V⁻¹s⁻¹)
- GaAs & InAs surface : zinc-blende structure has some polar surfaces (ex. (111) and $-(111)$)
- Polar surface energy : there were some results with energy density approximation approach
- New approach : by changing geometry, polar surface energy can be calculated directly
- Purpose : calculation of InAs surfaces without approximation

COMPUTATIONAL DETAILS

A. Computational details

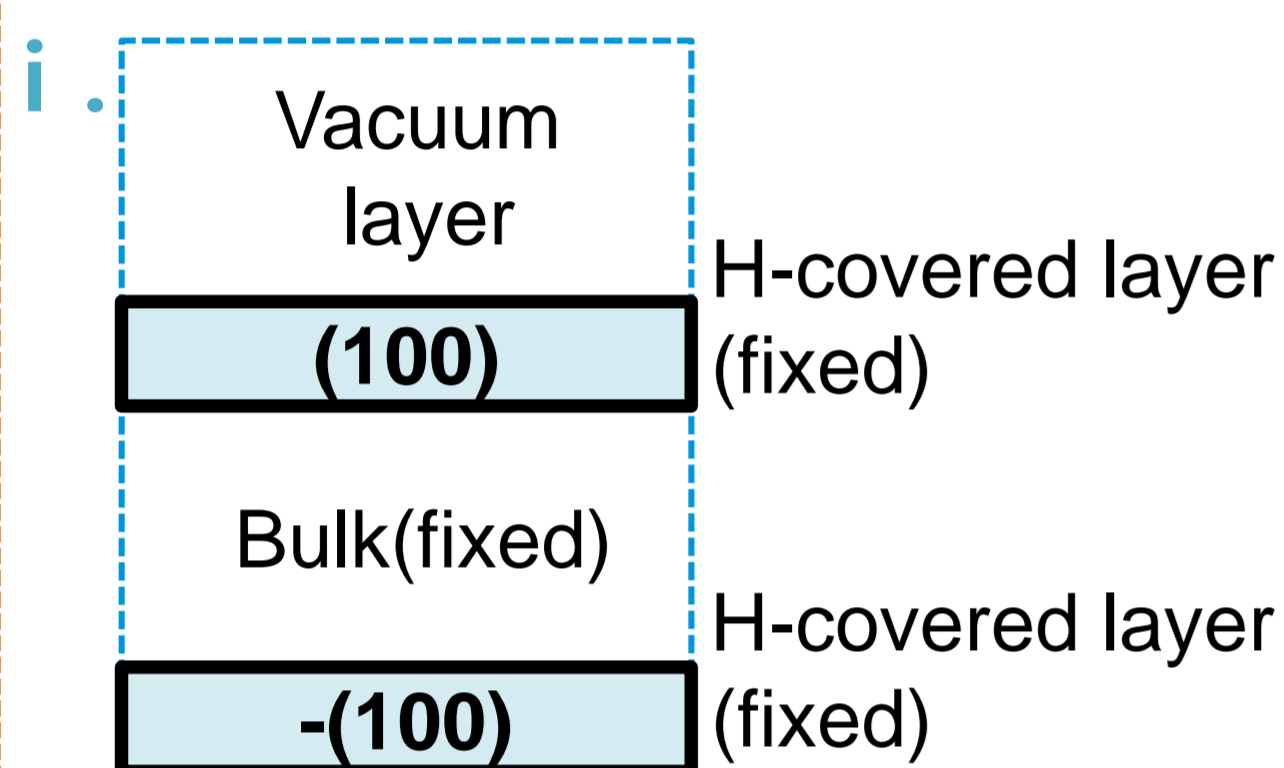
- VASP (Vienna *ab-initio* Simulation Package)
- xc-functional : GGA-PBE96, LDA-CA
- Cutoff energy : 300 eV
- k-points : According to convergence test for different slab structures
- Valence treatment : Ga=3d¹⁰4s²4p¹, As=4s²4p³, In=4d¹⁰5s²5p¹
- Vacuum thickness : 10 Å
- The top 5 layers of the total 9 layers were allowed to move
- The bottom of the layers were saturated with hydrogen and fixed

B. Equilibrium condition

- $\mu_{\text{In}} + \mu_{\text{As}} = \mu_{\text{InAs}} = \mu_{\text{In(bulk)}} + \mu_{\text{As(bulk)}} - \Delta H_f$
- $0 < -\mu_{\text{In}} + \mu_{\text{In(bulk)}} = \mu_{\text{As}} - \mu_{\text{As(bulk)}} + \Delta H_f$
- $-\Delta H_f < \mu_{\text{As}} - \mu_{\text{As(bulk)}} < 0$
- $\gamma_{\text{surface}} A = E_{\text{tot}} - \mu_{\text{In}} N_{\text{Ga}} - \mu_{\text{In}} N_{\text{As}} = E_{\text{tot}} - \mu_{\text{InAs}} N_{\text{In}} - \mu_{\text{As}} (N_{\text{As}} - N_{\text{In}})$

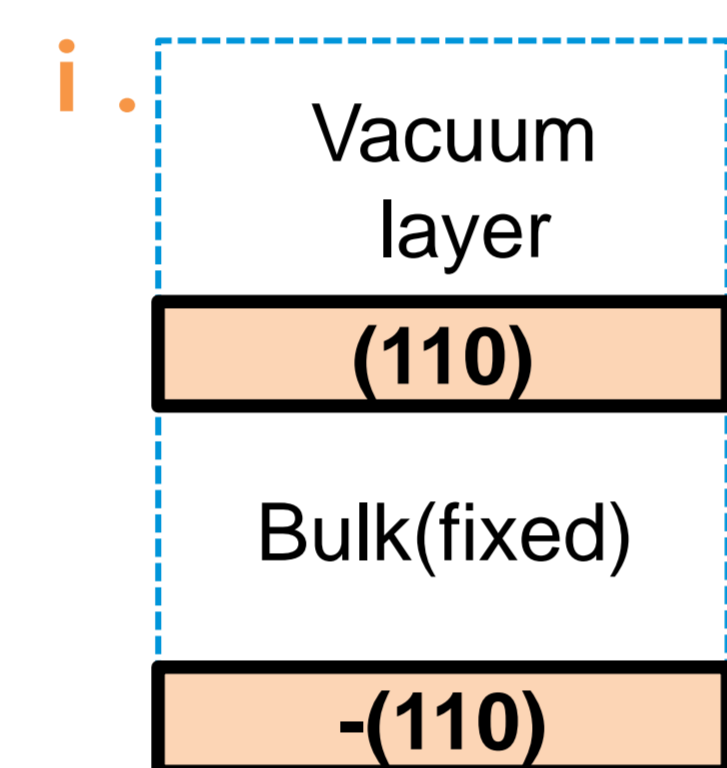
METHODOLOGY

A. (100) surface



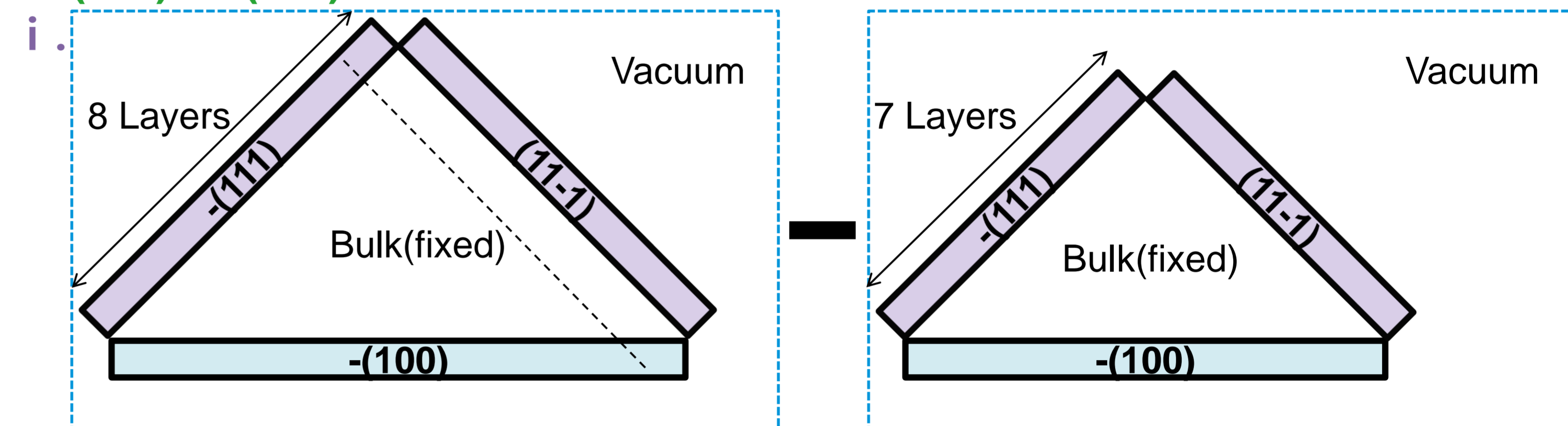
$$\gamma_{(100)-H} = (E_{\text{tot}} - \mu_{\text{Ga}} N_{\text{Ga}} - \mu_{\text{As}} N_{\text{As}}) / 2A$$

B. (110) surface

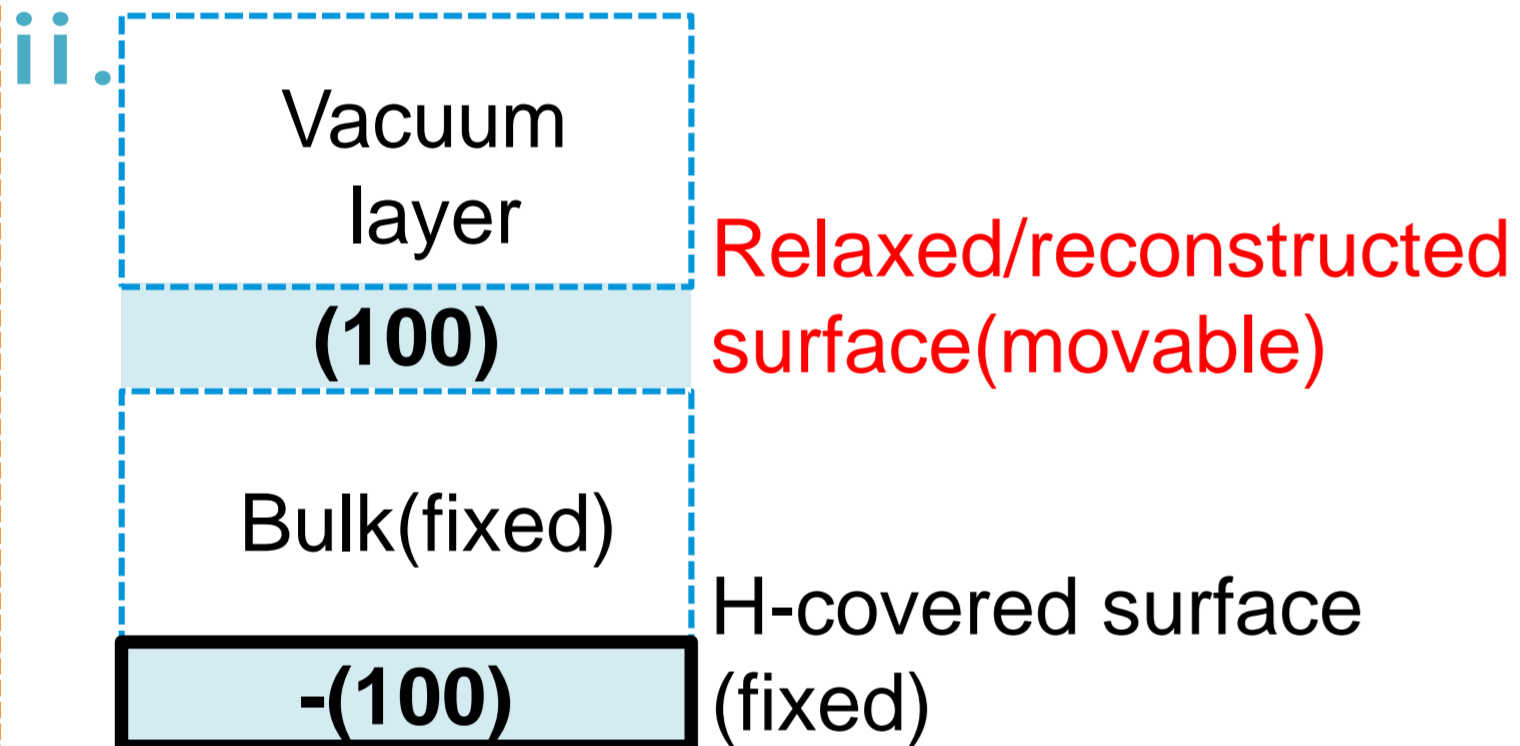


$$\gamma_{(110)-H} = (E_{\text{tot}} - \mu_{\text{Ga}} N_{\text{Ga}} - \mu_{\text{As}} N_{\text{As}}) / 2A$$

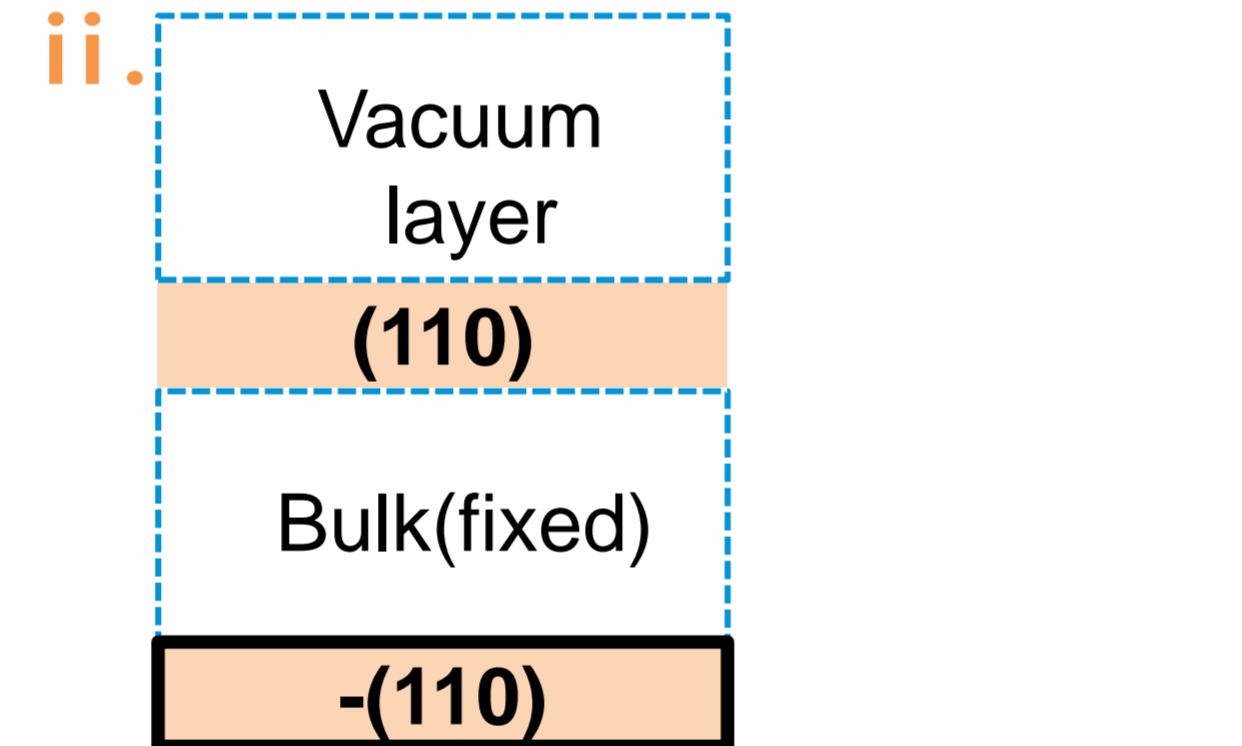
C. (111) & -(111) surface



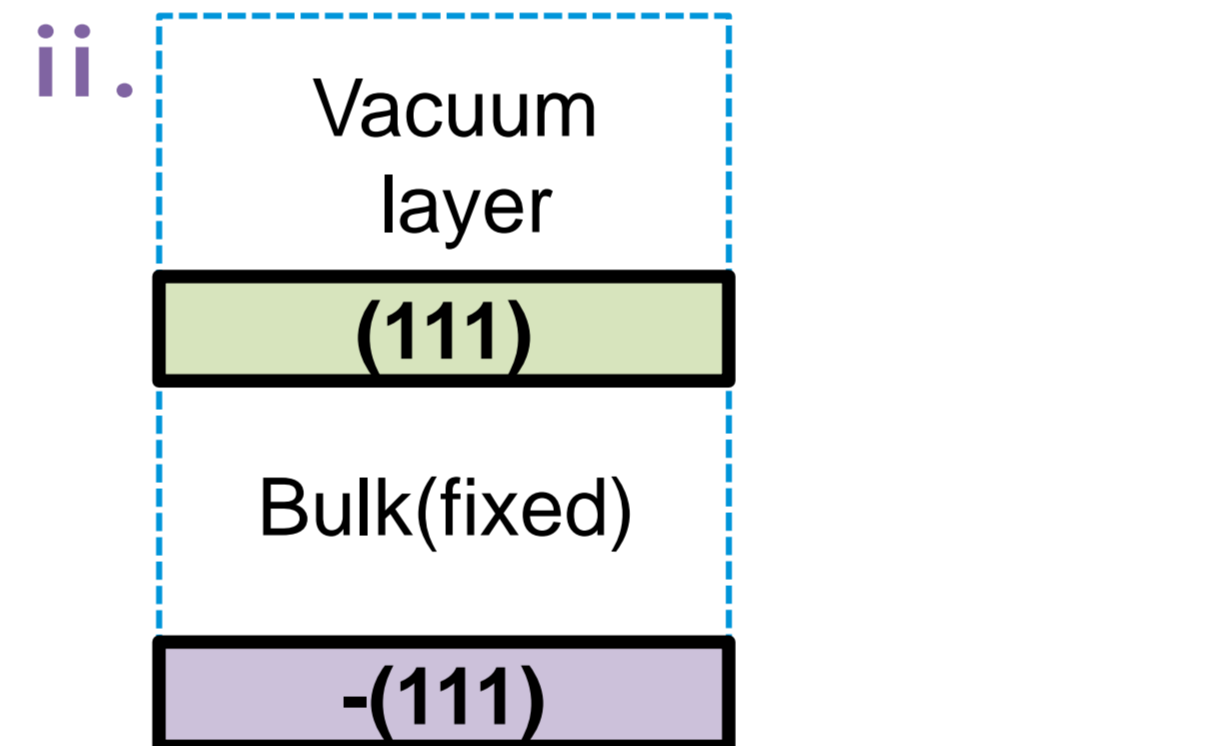
$$\delta E = E_{\text{tot}}(n=8; 36AB) - E_{\text{tot}}(n=7; 28AB) - 8\mu_{\text{AB}} = 2\gamma_{(-1-1-1)-H} + \gamma_{(-100)-H}$$



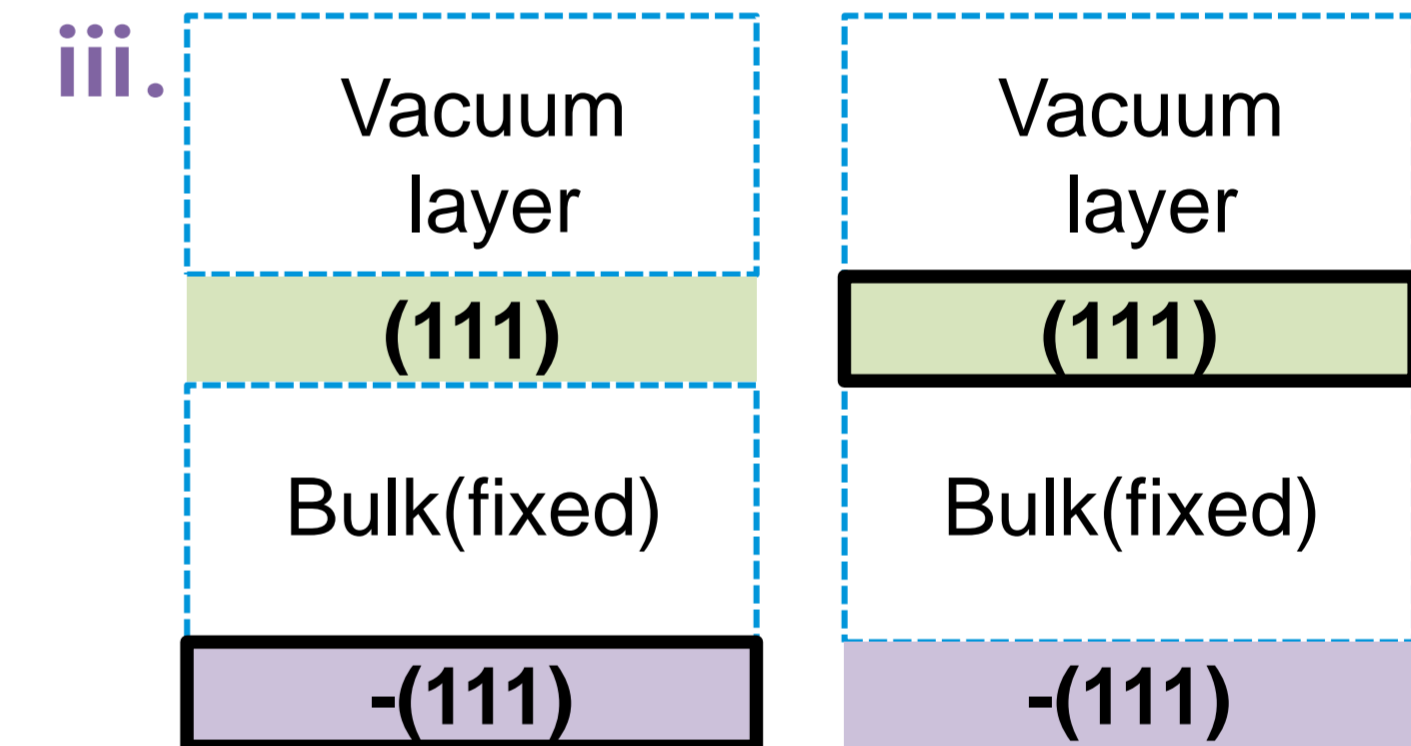
$$\gamma_{(100)} = (E_{\text{tot}} - \mu_{\text{Ga}} N_{\text{Ga}} - \mu_{\text{As}} N_{\text{As}}) / A - \gamma_{(100)-H}$$



$$\gamma_{(110)} = (E_{\text{tot}} - \mu_{\text{Ga}} N_{\text{Ga}} - \mu_{\text{As}} N_{\text{As}}) / A - \gamma_{(110)-H}$$



$$\gamma_{(111)-H} = (E_{\text{tot}} - \mu_{\text{Ga}} N_{\text{Ga}} - \mu_{\text{As}} N_{\text{As}}) / A - \gamma_{(-1-1-1)-H}$$

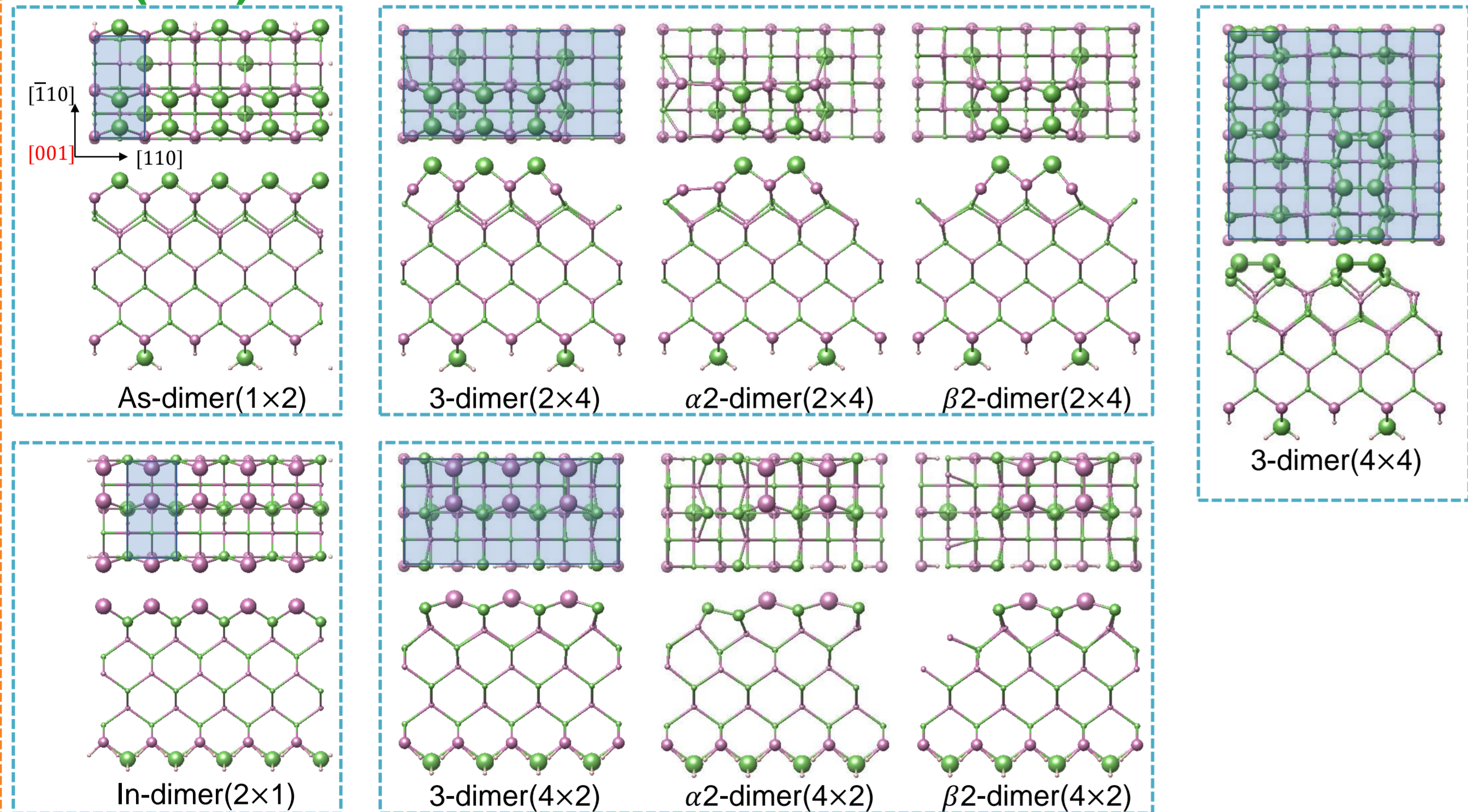


$$\gamma_{(111)} = (E_{\text{tot}} - \mu_{\text{Ga}} N_{\text{Ga}} - \mu_{\text{As}} N_{\text{As}}) / A - \gamma_{(-1-1-1)-H}$$

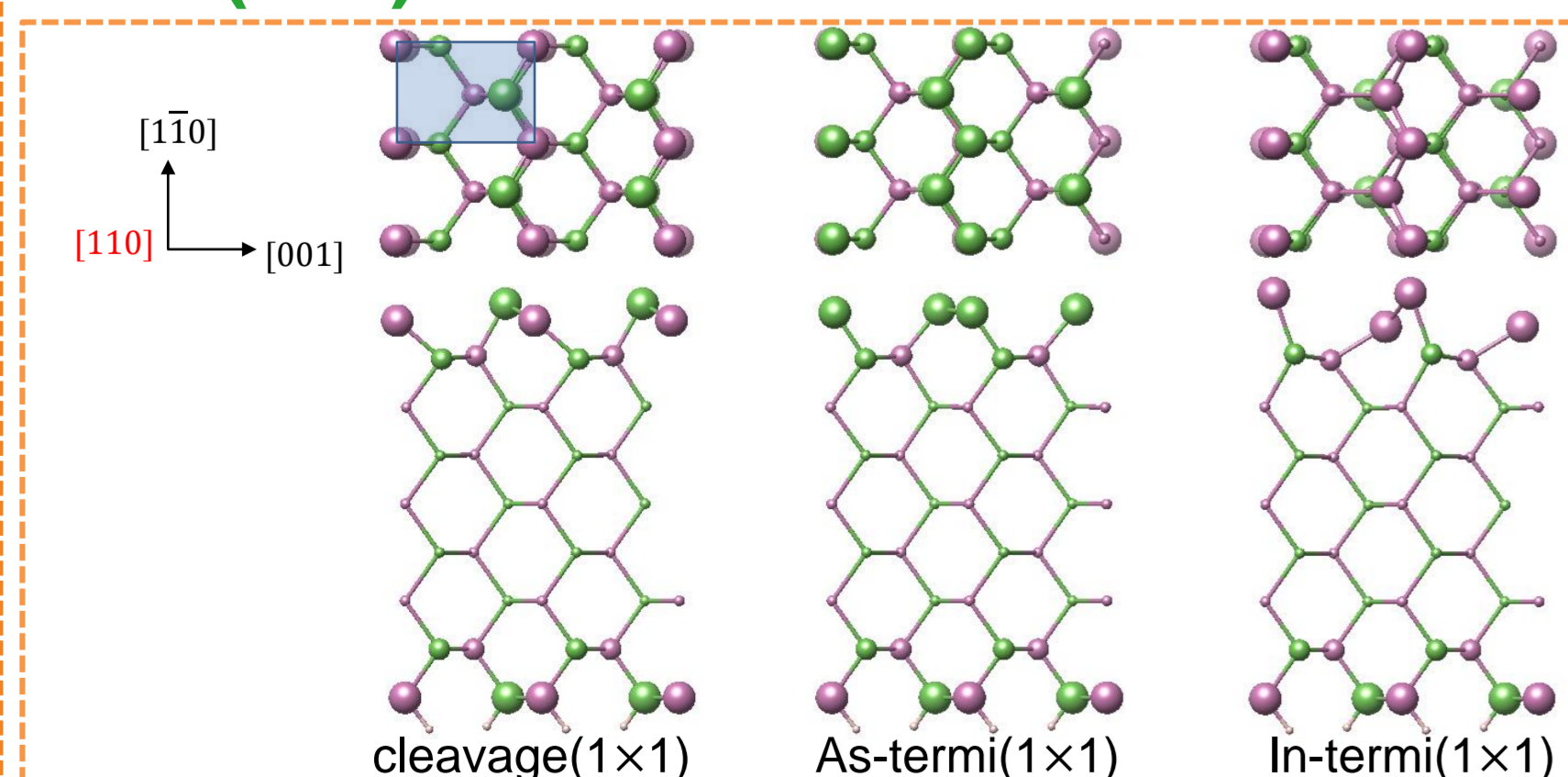
$$\gamma_{(-1-1-1)} = (E_{\text{tot}} - \mu_{\text{Ga}} N_{\text{Ga}} - \mu_{\text{As}} N_{\text{As}}) / A - \gamma_{(111)-H}$$

Results & discussions

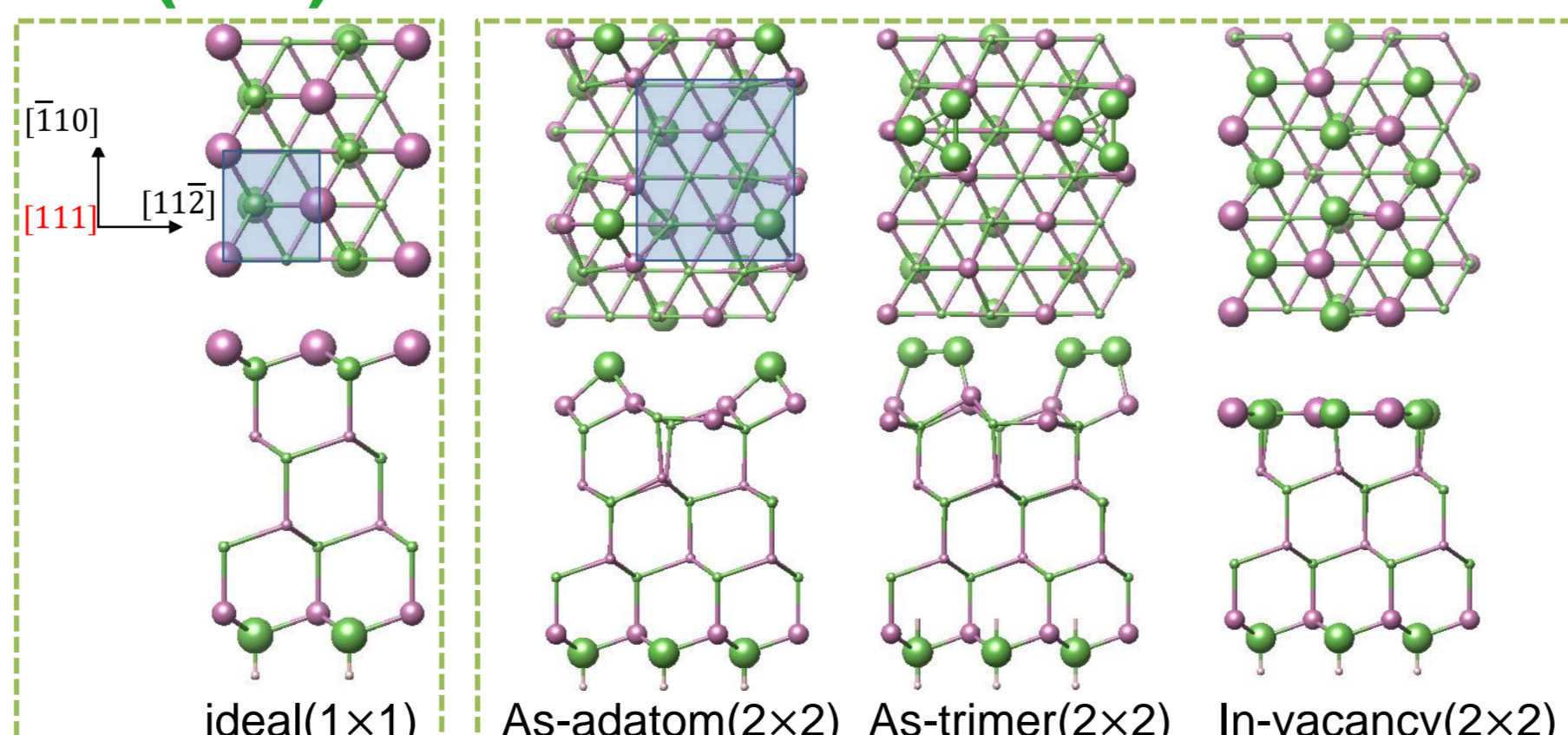
A. (100) surface reconstruction



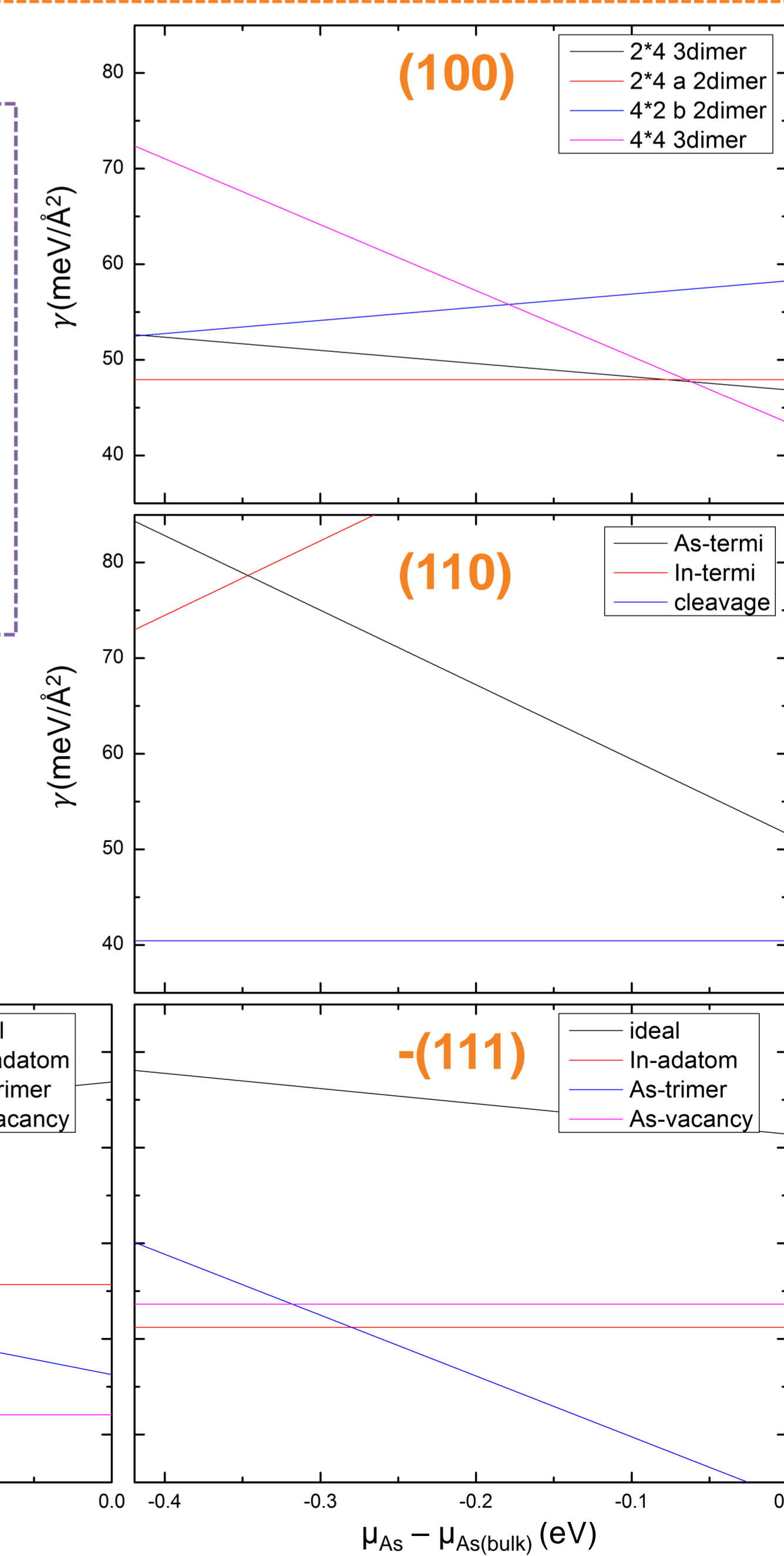
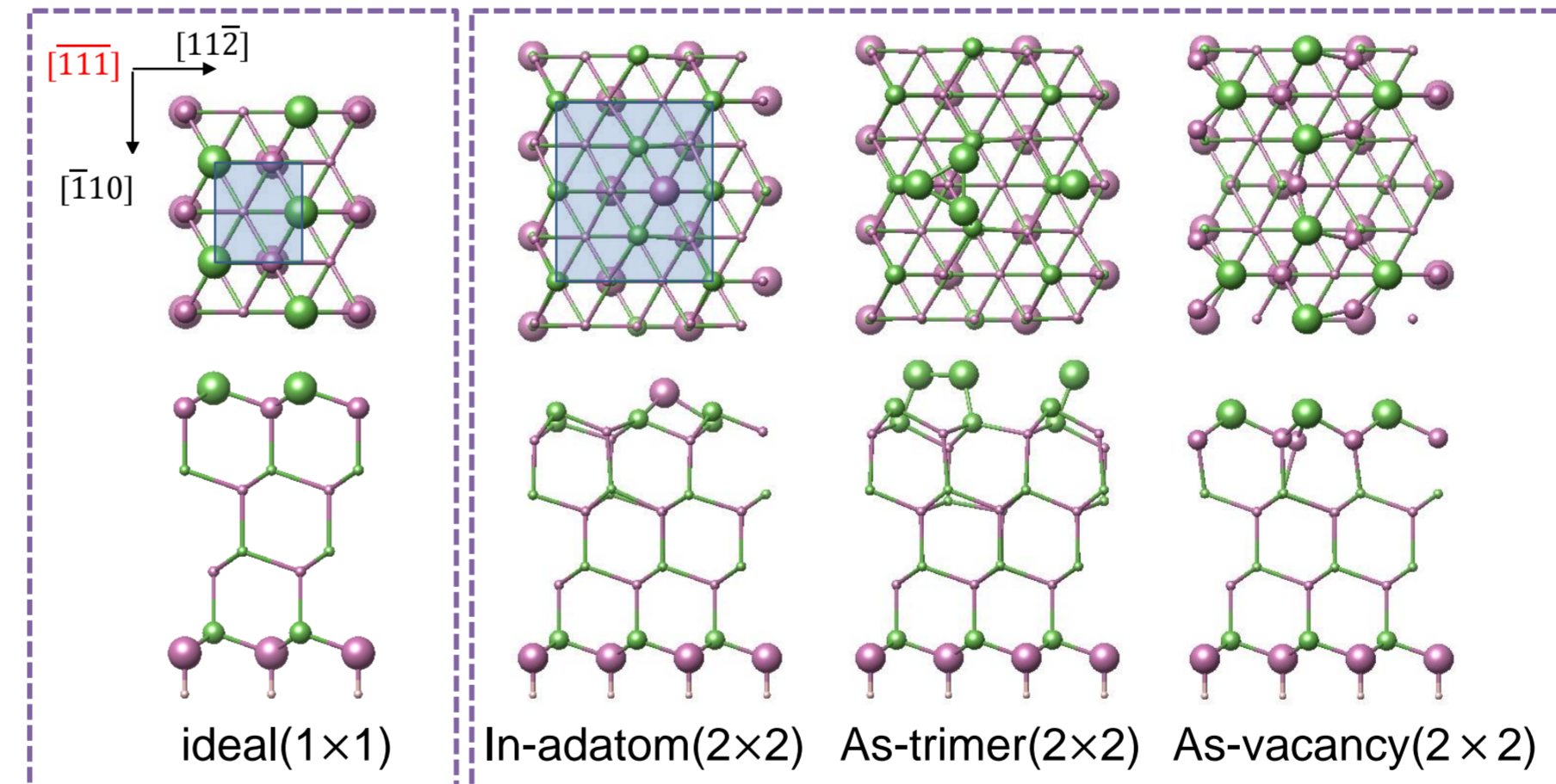
B. (110) surface reconstruction



C. (111) surface reconstruction



D. -(111) surface reconstruction



Summary

- Surface energies and surface structures were calculated by LDA functional
- In the In-rich region, $E(110) < E(111) < E(100) < E(-1-1-1)$: (110) cleavage is the most stable
- In the As-rich region, $E(-1-1-1) < E(110) < E(111) < E(100)$: $-(111)$ As-trimer is the most stable

References

- Physical Review B. 1996;54(12):8844.
- Physical Review B. 1998;58(8):4566-71.
- Phys. Rev. Lett. Volume 92, Number 8 (2004)